Electronic supplementary information

Co-modification of WO₃ nanoplates with **B-FeOOH/carbon** quantum dots combined with plasma treatment enabling high-efficiency photoelectrochemical characteristics

Jui-Teng Lee^a, Zhi-Cheng Yan^a, Kuan-Han Lin^a, Po-Hsuan Hsiao^a, Pin-Chao Liao^b, Ying-Chih Pu^c, and Chia-Yun Chen^{a,b,d,e*}

^aDepartment of Materials Science and Engineering, National Cheng Kung University, Tainan 70101, Taiwan. *Email: timcychen@mail.ncku.edu.tw

^bProgram on Semiconductor Packaging and Testing, Academy of Innovative Semiconductor and Sustainable Manufacturing, National Cheng Kung University, Tainan 70101, Taiwan.

^cDepartment of Materials Science, National University of Tainan, Tainan, 70005, Taiwan.

^dProgram on Smart and Sustainable Manufacturing, Academy of Innovative Semiconductor and Sustainable Manufacturing, National Cheng Kung University, Tainan 70101, Taiwan.

^eHierarchical Green-Energy Materials (Hi-GEM) Research Center, National Cheng Kung University, Tainan 701, Taiwan.

*Email: <u>timcychen@mail.ncku.edu.tw</u>

S1 Morphological investigations and correlated band diagram of WO₃-nanoplate based photoanode

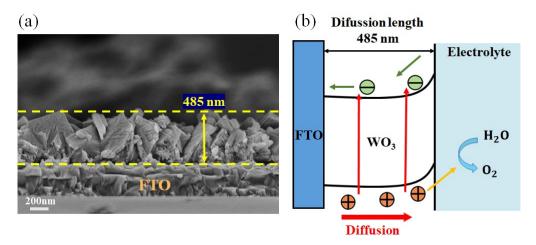
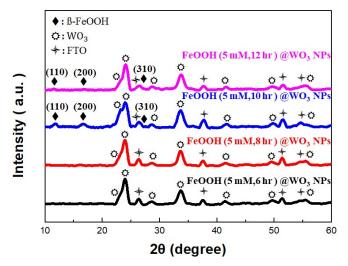


Fig. S1 (a) Cross-section SEM image of WO₃ NPs directly grown on FTO substrate.

(b) Schematic diagram of hole transport across interfaces between WO₃ NPs and electrolytes.



S2 XRD characterizations and LSV measurements of various FeOOH@WO₃ photoanodes

Fig. S2 XRD patterns of prepared β -FeOOH@WO₃ NPs via four various synthetic durations.

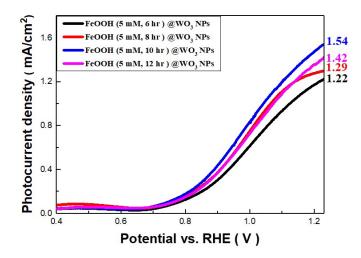


Fig. S3 LSV curves of prepared β -FeOOH@WO₃ NPs via three various synthetic durations. It should be pointed out that the photoanode reported here does not possess the capability to fully split water due to the employment of counter electrode [1-3].

S3 Featuring band diagram of FeOOH@WO₃ NPs with and without undergoing plasma treatment

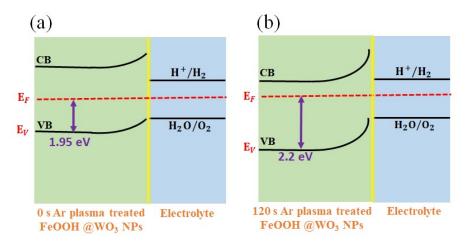


Fig. S4 Schematic illustrations of band diagrams of hybrid FeOOH@WO₃ NPs (a) without plasma treatment and (b) with plasma treatment for 120 s.

S4 Morphological evolutions and chemical compositions of photoanodes under plasma treatment

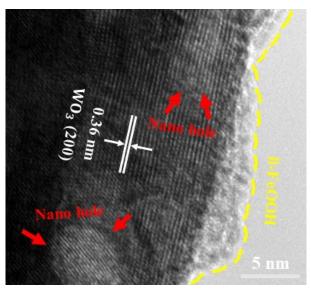


Fig. S5 Representative HRTEM image of p-FeOOH@WO₃ NPs after undergoing 150 s of plasma treatment, where the distorted microstructures are evidenced.

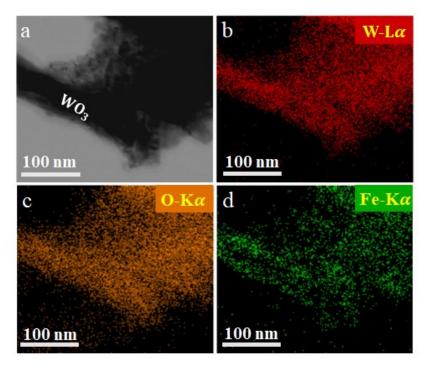


Fig. S6 (a) Representative TEM image of p-FeOOH@WO₃ NPs after undergoing 120 s of plasma treatment, indicating that composite structures are retained without showing distorted features. Corresponding EDS elemental mappings p-FeOOH@WO₃ NPs (120 s) of (b) W element, (c) O element and (d) Fe element, which visualize the uniform compositions of hybrid photoanodes.

S5 Microstructural analysis and size distribution of synthesized CQDs

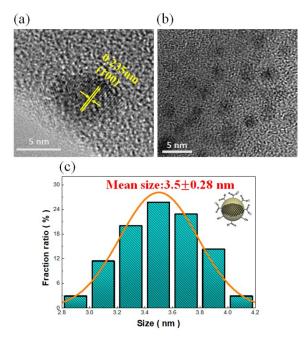
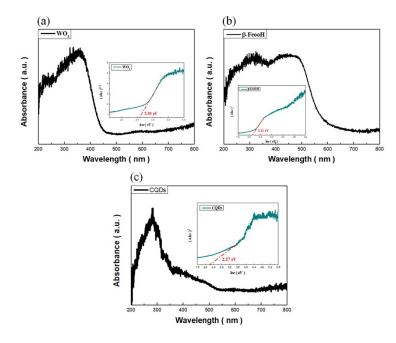


Fig. S7 (a) Representative HRTEM image of a CQD with featured (100) crystallite

fringes. (b) Low magnification TEM image of CQDs, showing the uniform size distributions of obtained CQDs. (c) Estimation of correlated size distributions.



S6 Experimental estimation of band structures

Fig. S8 UV-vis absorption spectra and correlated Tauc examination of (a) bare WO_3 NPs, (b) β -FeOOH NCs and (c) CQDs.

The analyses of band structures are employed by viture of Tauc plot and UPS measurements. The Tauc plot is obtained by plotting $(\alpha hv)^2$ against hv from UV-Vis absorption spectra, followed by determining the intercept of the tangent line with the X-axis in the Tauc plot to determine the Band gap of the material. Here, α represents the absorption coefficient, h is the Planck constant, and v is the frequency. According to the Tauc plot results, the band gaps of WO₃, β -FeOOH, and CQDs are found to be 2.76 eV, 2.11 eV, and 2.27 eV, respectively. In addition, UPS analysis is employed to estimate the practical position of the valence band using the following formula [4], $|VB| = hv - (E_{cutoff} - E_R)$ (1) where VB the energy level of valence band, hv the incident photon energy (21.2 eV), $E_{res} = 6\pi f$

 E_{cutoff} the energy corresponding to the intersection of extension of vertical line segment and the baseline in the UPS spectrum, E_R the energy corresponding to the intersection of epitaxial tangent at the initial rise and the baseline. Accordingly, the valence band energies of WO₃, β -FeOOH, and CQDs are measured to be -7.69 eV, -5.96 eV, and -5.82 eV, respectively.

Table S1. Extracted valence band minimum, conduction band maximum and bandgap energy of investigated structures from the interplay of UPS and UV-Vis lightabsorption measurements

	Valence band (eV)	Conduction band (eV)	Band gap (eV)
WO ₃	-7.69	-5.16	2.53
β-FeOOH	-5.96	-3.85	2.11
CQDs	-5.82	-3.55	2.27

S7 Analytic XPS spectra of p- FeOOH@WO₃ NPs

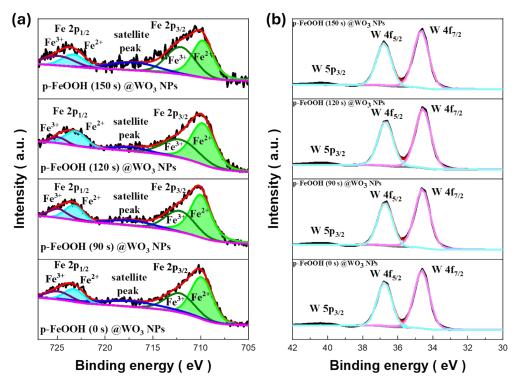


Fig. S9 Analytic XPS spectra of (a) Fe 2p and (b) W 4f for 0 s, 90 s, 120 s, 150 s of p-FeOOH@WO₃ photoanodes. The results from Fe 2p spectra indicate that, under plasma treatment durations of 0, 90, 120, and 150 s, the ratios of Fe²⁺ to Fe³⁺ are observed to be 1.50, 1.61, 1.82, and 1.11, respectively. These findings are in line with the quantitative evolutions shown in Fig. 4 of main text. Furthermore, the results of the W 4f spectra demonstrate the consistent signals of W4f_{5/2}, W4f_{7/2}, and W5p_{3/2} of samples with or without experiencing the plasma treatment.

S8 Detailed electrochemical CV examinations

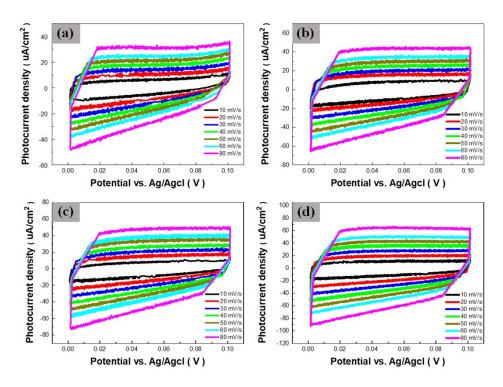


Fig. S10 Electrochemical CV results obtained from the non-Faradic region: (a) Bare WO₃ NPs, (b) FeOOH@WO₃ NPs, (c) p-FeOOH@WO₃ NPs and (d)CQDs/p-FeOOH @WO₃ NPs.

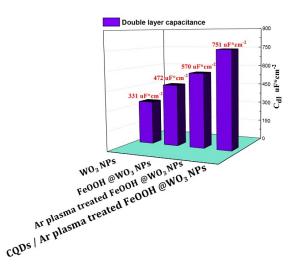


Fig. S11 Comparisons of double layer capacitance (C_{dl}) values from four different photoanode designs.

S9 Faradaic efficiency of O2 and H2 production in the presence of designed photoanodes

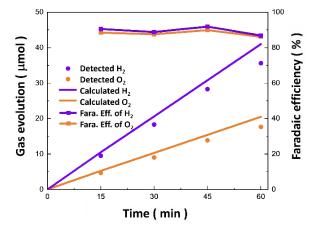


Fig S12 Calculated and measured Faradaic efficiencies at 1.23 V vs. RHE. The results show that after 60 min of water oxidation reaction, the actual yields of hydrogen and oxygen are approximately 35.6 μ mol and 17.7 μ mol, respectively. In addition, the Faradaic efficiencies for hydrogen and oxygen are estimated to be 89.5% and 88.0%, respectively. highlighting the effectiveness of dual-modification strategies in enhancing water oxidation activity.

S10 Dynamic CV measurement of FeOOH (5 mM)@WO3 NPs during PEC process

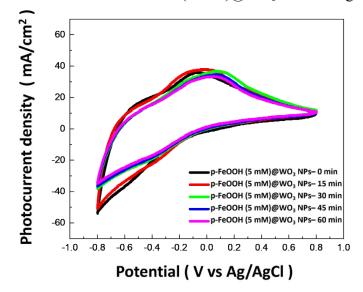


Fig. S13 The dynamic CV measurement of FeOOH (5 mM)@WO₃ NPs during the PEC test. Long-term photoelectrochemical tests of designed photoanodes spanning 0-60 min were conducted [5]. To examine the dynamic changes, the CV results of samples were extracted at every 15 min, with a scan range from 0.8 V to -0.8 V. The results show the consistent oxidation signal at around 0.1 V corresponding to the oxidative conversion of Fe²⁺ states. These findings clearly confirm the existence of Fe²⁺ within electrochemical cycles in all samples.

S11 Morphological characterizations of p-FeOOH@WO₃ NPs after conducting PEC tests

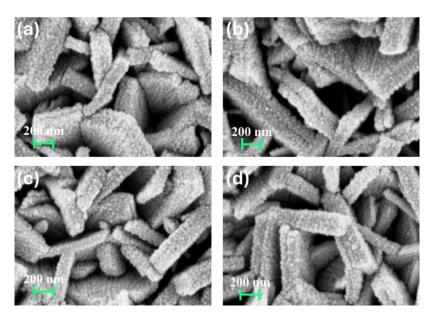


Fig. S14 Top-view SEM images of FeOOH (5 mM)@WO₃ NPs (a) before and (b) after 120 s of Ar plasma treatment. Top-view SEM images of p-FeOOH (5 mM)@WO₃ NPs (120 s of plasma treatment) after experiencing (c) 1-hour and (d) 2-hour photoelectrochemical reactions. The results confirm that no obvious morphological variations of photoanodes after experiencing plasma treatment (120 s) and long-term photoelectrochemical tests.

S12 Mott-Schottky test of FeOOH@WO3 NPs before and after plasma treatment

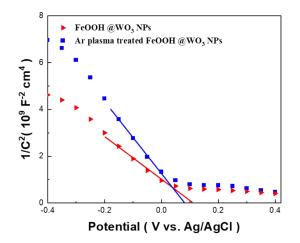
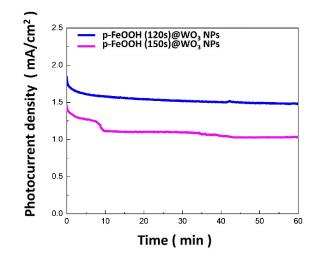


Fig. S15 Measured Mott-Schottky plots of FeOOH@WO₃ NPs before and after Ar plasma treatment. The results indicate that without plasma treatment, the flat band potential of FeOOH@WO₃ NPs at p-type side was measured to be 0.11 V, whereas the

flat band potential of plasma-treated photoanodes was decreased to 0.08 V, suggesting the hole transfer from WO3 NPs to FeOOH that causes the reduction of Fermi level due to p-type doping. Along with photoelectrochemical measurements presented in the main text, these results confirm that the emergence of plasma treatment is effective for inducing band bending at interfaces and facilitates the injection and transport of photogenerated holes.



S13 Stability examinations of p-FeOOH@WO3 NPs with various treatment durations

Fig. S16 Stability examinations of photocurrent density versus time in the presence of p-FeOOH @WO₃ photoanode at 1.23 V vs. RHE under the stimulated-light irradiations (100 mW cm⁻²). The outcomes reveal that the p-FeOOH (120 s)@WO₃ NPs exhibit a stable photocurrent density over an extended period during the stability assessment. In contrast, the photocurrent density of p-FeOOH (150 s)@WO₃ NPs displays significant decrease observed at 8.75 min, indicating that the prolonged plasma treatment may cause the structural degradation of photoanodes. These long-term tests confirm that the emergence of plasma treatment for 120 s represents the optimal solution for both long-term stability and durability.

S14 Comparative table of state-of-art photoanode designs and this work

Table S2 Details of PEC measurements of various photoanode designs

Photoanode materials	Illumination conditions	Eletrolytes	Standard photocurrent density	Ref
WO ₃ /MOS ₂	AM 1.5G	0.5 M H ₂ SO ₄	0.96 mA /cm ² at 1.23 V vs.RHE	[25]
WO ₃ /CuWO ₄	500 W X e lamp, $\lambda > 400 \text{ nm}$	0.2 M Na ₂ SO ₄	1.21 mA /cm ² at 1.5 V vs.Ag/AgCl	[26]
WO ₃ /a-Fe ₂ O ₃	300 W Xe lamp, AM 1.5G	0.1 M Na ₂ SO ₄	1 mA /cm ² at 1.23 V vs.RHE	[27]
WO ₃ /BiVO ₄	AM 1.5G	$0.5 \text{ M} \text{ Na}_2 \text{SO}_4$	1.76 mA /cm ² at 1.23 V vs.RHE	[28]
WO ₃ /TiO ₂ / NiTCPP	AM 1.5G	$0.5 \text{ M} \text{ NaSO}_4$	2.07 mA /cm ² at 1.23 V vs.RHE	[29]
WO ₃ /CuO	AM 1.5G	0.5 M Na ₂ SO ₄	1.84 mA /cm ² at 1.23 V vs.RHE	[32]
WO ₃ /ZnWO ₄ /ZnO	500 W Xe lamp	0.35 M Na ₂ S and 0.25 M NaSO ₃	1.57 mA /cm ² at 1.23 V vs.RHE	[50]
WO ₃ /rGO/Sb ₂ S ₃	AM 1.5G	0.5 M Na ₂ SO ₄	1.20 mA /cm ² at 1.23 V vs.RHE	[51]
WO ₃ /BiVO ₄ / Bi ₂ S ₃	AM 1.5G	$\begin{array}{ccc} 0.1 & M & of \\ Na_2SO_3 \mbox{ and } 0.1 \\ M & of & Na_2S \\ mixed \mbox{ solution} \end{array}$	1.52 mA /cm ² at 1.23 V vs.RHE	[52]
WO ₃ /BiVO ₄ / TiO ₂	1000 W Xe lamp, AM 1.5G	$0.1 \mathrm{~M~Na_2SO_4}$	4.2 mA /cm ² at 1.23 V vs.RHE	[53]
WO ₃ /PPy:Ru 4POM	300 W Xe lamp	0.1 M HCl	2.5 mA /cm ² at 1.23 V vs.RHE	[54]
WO ₃ /C-M2P- CoOx	300 W Xe lamp, AM 1.5G	0.1 M Na ₂ SO ₄	3.5 mA /cm ² at 1.23 V vs.RHE	[55]
CQDs/p- FeOOH@W O ₃	100 W Xe lamp, AM 1.5G	0.1 M Na2SO4	2.18 mA /cm ² at 1.23 V vs.RHE (open- circuit voltage of 0.425 V)	This work

Reference

- 1. Lopes, P. Dias, L. Andrade and A. Mendes, *Solar Energy Materials and Solar Cells*, 2014, **128**, 399-410.
- 2. S.S. Kalanur, I.-H. Yoo, K. Eom and H. Seo, *Journal of Catalysis*, 2018, **357**, 127-137.
- 3. Y. Zhao, S. Balasubramanyam, R. Sinha, R. Lavrijsen, M.A. Verheijen, A.A. Bol and A. Bieberle-Hütter, *ACS Applied Energy Materials*, 2018, **1**, 5887-5895.
- 4. H.W. Du, J. Yang, Y.H. Li, F. Xu, J. Xu and Z.Q. Ma, *Applied Physics Letters* 2015, **106**, 093508.
- 5. H. Ma, Y. Zheng, J. Xian, Z. Feng, Z. Li and F. Cui, *Chemosphere*, 2022, **296**, 133994.